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Active Vapor Split Adjustment for Energy Optimal Control of Dividing Wall Distillation Columns: Experimental Studies

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Active Vapor Split Adjustment of DWC

Outline

Introduction

- Conventional Distillation
- Thermally coupled columns
- Need for active vapor split
 - 4-product Kaibel column
 - 4-product Kaibel column: Control Structure
 - V_{min} vs R_v
 - Summary
- 3 Experimental setup
 - Pilot Plant: 4–Product Kaibel column

4 Experimental Results

- Valve behaviour
- Total Reflux
- 4–Product Kaibel column
- 5 Conclusion

Conventional distillation

- energy intensive
 - large mixing losses
 - at interconnections
 - internal remixing
 - difficult seperation first
 - large ΔT at exchangers



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Thermally coupled columns

• examples: prefractionator arrangements

- Petlyuk column
 - originally proposed for 3 product
 - can be extended to more than 3 products
 - easiest separation first
 - low mixing losses
 - energy saving upto 50 % for 4-component
- Kaibel Column
 - energy saving upto 30 % for 4-component

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Thermally coupled columns

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• can be realized by divided-wall columns (DWC)

4-product Kaibel column

- A: methanol
- B: ethanol
- C: propanol
- D: butanol

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4–product Kaibel column



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4-product Kaibel column: Control Structure

Regulatory layer when $V > V_{min}$

- 4 point temperature control
- inventory control
- fixed V & Rv

• demonstrated experimentally



4-point control: Experiments



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4-product Kaibel column: Control Structure

Regulatory layer when $V = V_{min}$

- 5 point temperature control
- inventory control
- also use Rv



V_{min} vs R_v

boilup (V_{min}) vs Vapor Split (R_v)



- $z_F = equimolar$
- purity spec: 98% for all products



Figure: V_{min} vs R_v

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boilup (V_{min}) vs Vapor Split (R_v) changes with disturbances



Figure: V_{min} vs R_v

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• active vapor split control required

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 - to remain close to optimum R_v and V_{min}
 - to aid to flexibility in optimal operation for varying disturbances

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- Problem: Vapor Split may/will be uncertain
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- In four point control
 - RI is very precise input: can be used in optimizing layer
 - Rv is uncertain input: can be used in regulatory layer with feedback

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Pilot Plant





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Vapor Split Valves





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stepper motor

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Split range logic



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Vapor valve characteristics- Manual mode



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Vapor valve characteristics- Manual mode



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Vapor valve characteristics- Manual mode



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Experiments: total reflux

- total reflux conditions
- valve control: split range logic
- control variable:
 - $\Delta T = T2 T5$



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Run



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Experiments: 4–Product Kaibel column

- 4-point temperature control
- 1 temperature in prefractionator controlled with Rv *in place of Rl*
 - control variable: T2
- 3 temperature controlled with L, S1 & S2
 - control variable: T3, T5 & T6
- RI is very precise input
 - can be used as optimizing input



Run



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Conclusions

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• Active vapor split is feasible

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 - in 4 point control: Rv *should* be used in regulatory layer, RI *can be* used for optimization

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- Further works needed

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- Further works needed
 - Superior valve design to operate in low pressure drop applications

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